

[On Page 1, line 10, before the "BACKGROUND OF THE INVENTION" section, please insert the following:

--CROSS REFERENCE TO RELATED APPLICATIONS:

The following applications contain subject matter related to the present application:

U.S. Patent No. 6,348,126 B1, issued February 19, 2002 entitled, "EXTERNALLY EXCITED TORROIDAL PLASMA SOURCE," By Hiroji Hanawa, et al.; U.S. Patent Application Serial No.: 09/636,434, filed August 11, 2000 entitled, "REACTOR CHAMBER FOR AN EXTERNALLY EXCITED TORROIDAL PLASMA SOURCE WITH A GAS DISTRIBUTION PLATE," By Hiroji Hanawa, et al.; ^{now U.S. Pat. 6,468,308} U.S. Patent Application Serial No.: 09/636,435, filed August 11, 2000 entitled, "EXTERNALLY EXCITED MULTIPLE TORROIDAL PLASMA SOURCE," By Hirojji Hanawa, et al.; ^{now U.S. Pat. 6,444,906} U.S. Patent Application Serial No.: 09/636,436, filed August 11, 2000 entitled, "A METHOD OF PROCESSING A WORKPIECE USING AN EXTERNALLY EXCITED TORROIDAL PLASMA SOURCE," By Hiroji Hanawa, et al.; ^{now U.S. Pat. 6,410,449} U.S. Patent Application Serial No.: 09/636,700, filed August 11, 2000 entitled, "EXTERNALLY EXCITED TORROIDAL PLASMA SOURCE USING A GAS DISTRIBUTION PLATE," By Hiroji Hanawa, et al.; ^{now U.S. Pat. 6,453,842} U.S. Patent Application Serial No.: 09/637,174, filed August 11, 2000 entitled, "EXTERNALLY EXCITED TORROIDAL PLASMA SOURCE WITH A GAS DISTRIBUTION PLATE," By Hiroji Hanawa, et al. ^{now U.S. Pat. 6,551,446}

11/20/03